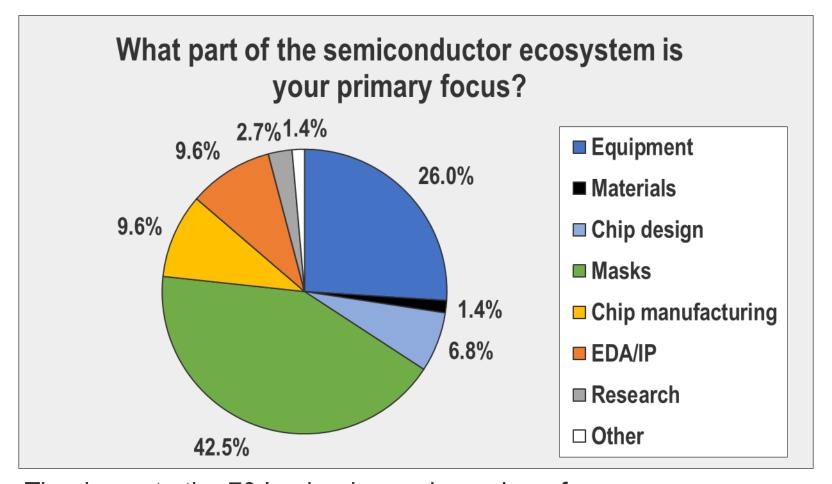
Our 5th Annual Perceptions Survey – 2016



Masks & Equipment total 68.5% of responses

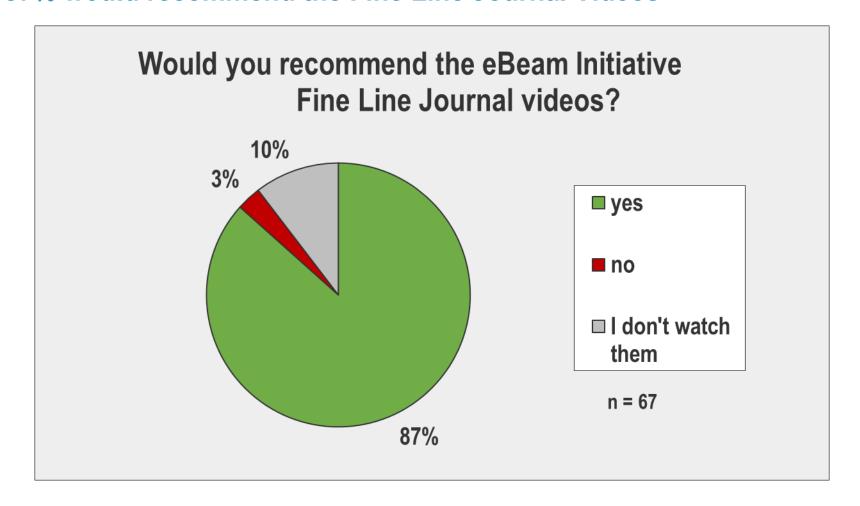


Thank you to the 73 luminaries and members for your responses (~30 companies represented)

Thanks for Watching Our Videos



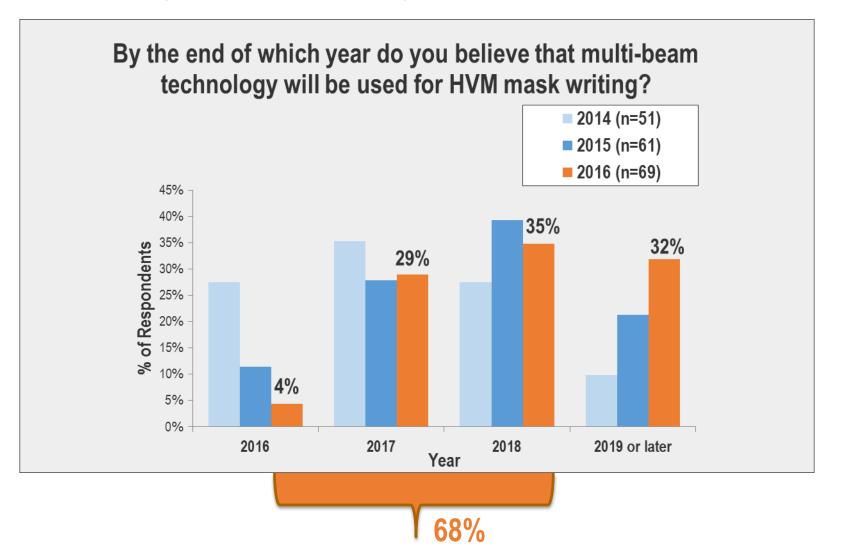
87% would recommend the Fine Line Journal Videos



68% Say Multi-beam HVM by end of 2018



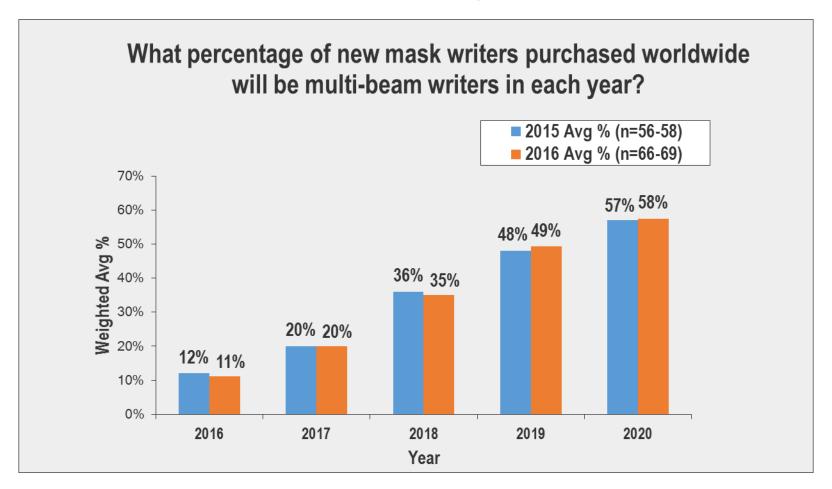
3 month change from 2015 Survey results



No Change in Multi-beam Purchasing Trend



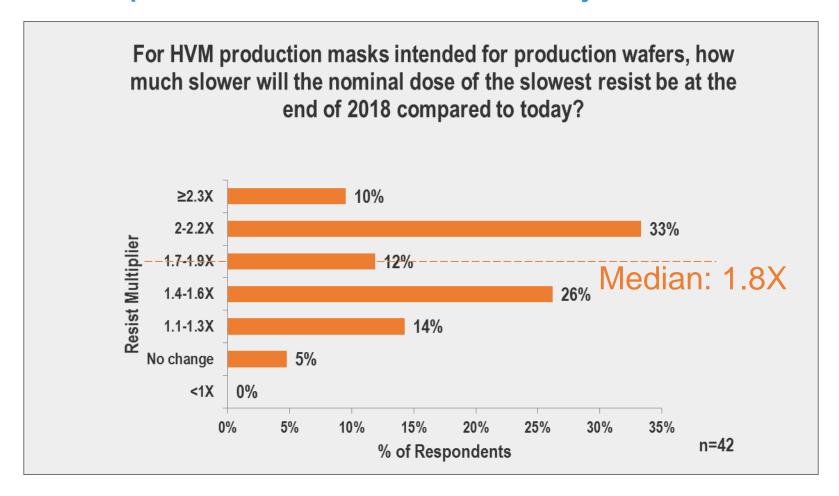
Some responded 100% for 2018 and beyond



Resists likely to be ~2X slower in 2 years



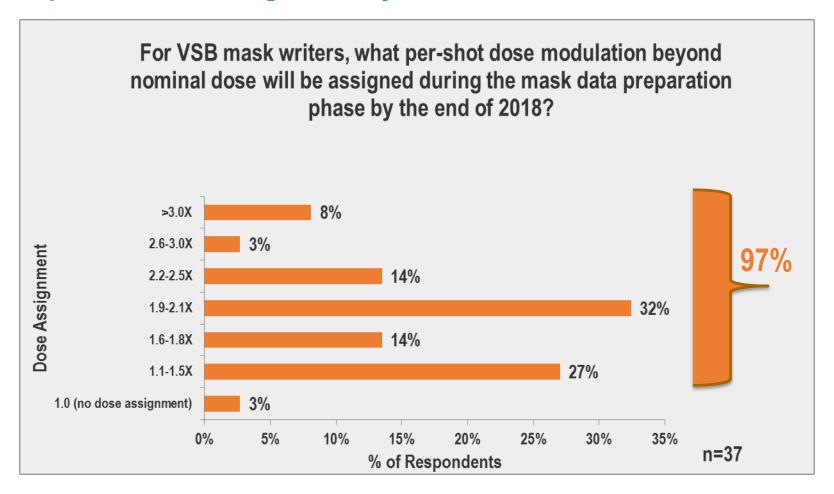
Median response around 1.8X slower than today



Almost Everyone Predicts Dose Modulation



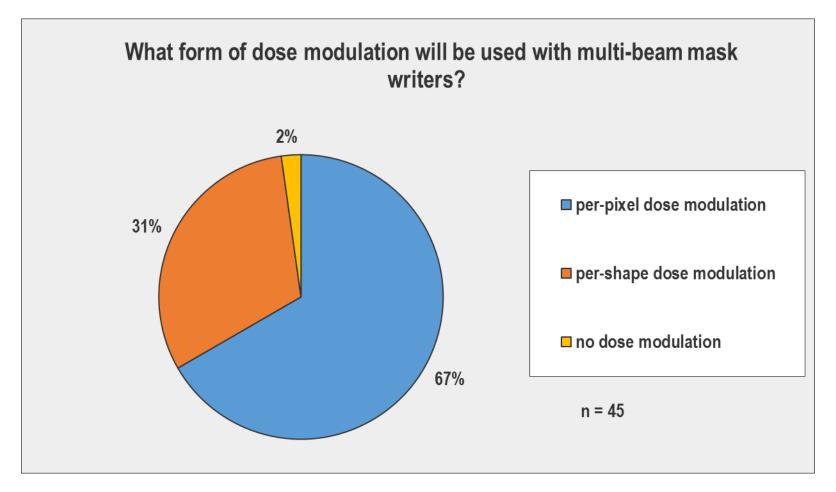
97% predict dose assignment by end of 2018



Dose Modulation Debate for Multi-beam



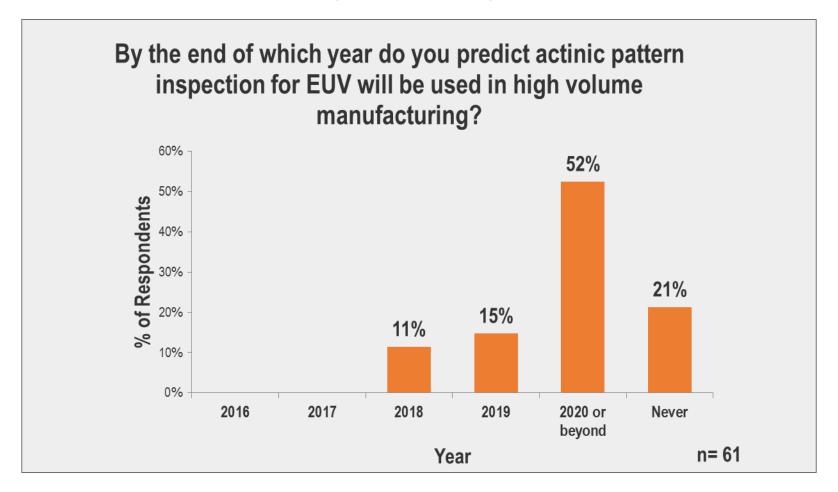
67% predict per-pixel; 31% per-shape



Actinic Inspection Predicted...Sometime



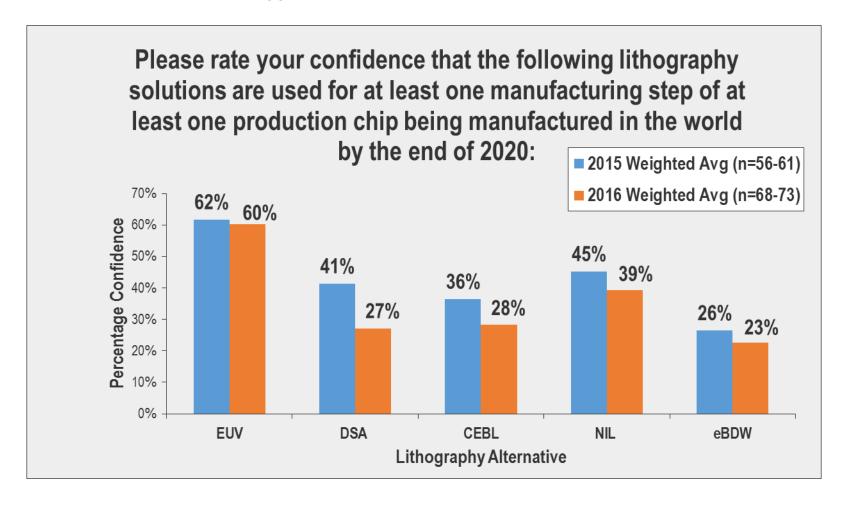
21% predict "never" in this year's survey



EUV Confidence Over Others Increased



EUV confidence at 60% overall

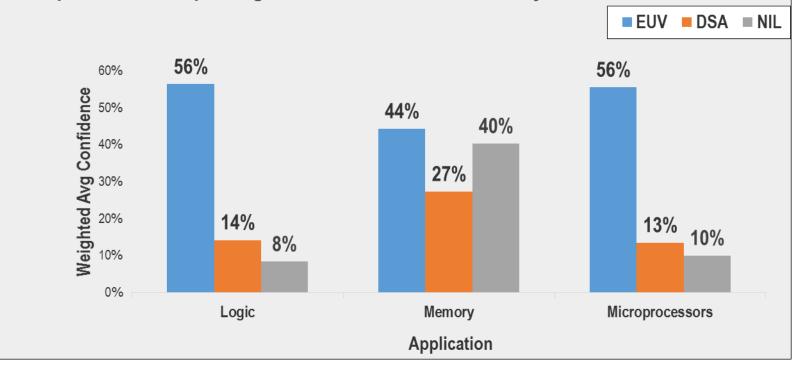


NIL Rivals EUV for Memory in Perception



NIL confidence at 40% for Memory

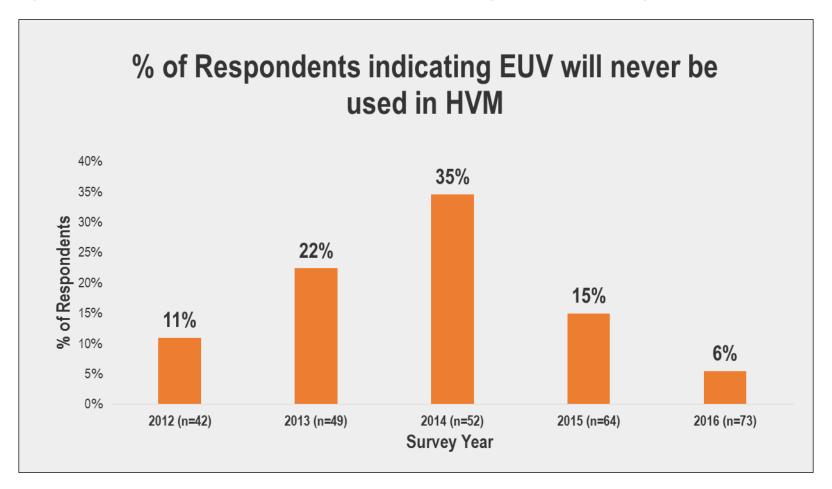
Per application segment, please rate your confidence that the following lithography solutions are used for at least one manufacturing step of at least one production chip being manufactured in the world by the end of 2020:



EUV Pessimism is the Lowest in 5 Years



Only 6% responded with "never" in this year's survey





Exciting Times Ahead

- Multi-beam for masks
- Dose modulation
- EUV and NIL
- And how will EUV masks be inspected?



Thank you to those who participated in the survey!

Feedback and questions for future surveys welcome – send to jan@williscalibra.com